Silicon Difluoride, a Carbene Analog. Its Reactions and Properties

JOHN L. MARGRAVE* AND PAUL W. WILSON†

Department of Chemistry, Rice University, Houston, Texas 77001

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The chemistry of the divalent compounds of the group IVb elements has received considerable attention in recent years. These studies have embraced carbene (CH₂), the carbon dihalides, silylene (SiH₂), dimethylsilylene, the silicon dihalides, and the germanium dihalides. This interest has been stimulated by the realization that these compounds are important intermediates in many reactions. More importantly, they can be used to make new compounds, both organic and inorganic, that can be prepared in no other way.

Since this field has proved to be so fruitful, it is somewhat surprising that much of its development has occurred over only the last decade. One reason is that the difluoride is invariably the most stable and longlived divalent compound of a group IV element; e.g., carbene has a half-life of about 1 msec in the gas phase whereas carbon difluoride has a half-life of 1 sec. The entire field of fluorine chemistry has been retarded by the lack of suitable materials for constructing apparatus, but this should have been less of a handicap for the group IVb fluorides than for other fluorides inasmuch as CF₄ and SiF₄ do not attack glass. Apparently the lack of development of the general fluorine field also delayed the investigation of the group IV fluorides. Since the most stable members of this family were not studied, the members of lesser stability received virtually no attention, with the exception of carbene itself.

Another problem which delayed the study of the group IV dihalides is the fact that many of them are transient species under the conditions in which they are normally prepared. Improvements in instrumentation over the last decade have permitted studies of these short-lived species which were not possible earlier.

At Rice University studies of the divalent compounds of group IV elements have become a major research area. Investigations have ranged over many of the divalent species—SiO, SiS, GeF₂, GeCl₂, GeO, GeS, SnF₂, PbF₂, etc.—but silicon difluoride has been the compound of principal interest. In this Account, some of its properties and reactions are described. Many of these reactions have led to unusual products, suggesting that use of this compound will become very important in the synthesis of organic and inorganic silicon compounds.

In the early literature, there are several reports claiming the preparation of SiF₂. Actually these reports deal with reactions of polymeric silicon difluoride.

† Present address, A.A.E.C. Research Estb., Lucas Heights, Australia.

Such polymers can be prepared by reducing SiF₄ using heated Si, Al, or Mg.¹ Although it was suggested that monomeric SiF₂ was an intermediate in the formation of these polymers, its presence was not definitely established. At about the same time, spectroscopic² and mass spectrometric investigations³ showed that at least small amounts of gaseous SiF₂ could be prepared. All of this led to an extensive and systematic study of the properties of silicon diffuoride.

Preparation of Silicon Difluoride. Silicon difluoride is relatively easy to make.⁴ The apparatus used is shown in Figure 1. Commercially available SiF_4 is passed into a reservoir and then, using needle valve controls, it is passed over lumps of SiF_4 is heated to 1200° . This gives a yield of about 50% SiF_2 , with the remainder being SiF_4 . If the pressure of SiF_2 is more than 1–2 Torr, there is some disproportionation. To avoid this the system is pumped continuously. As soon as the SiF_2 is formed, it is swept through the vacuum line to a point where it can react or its physical properties can be examined.

A major point of the initial studies was to show that monomeric SiF_2 was being formed.⁴ The SiF_2 – SiF_4 mixture was led from the hot column into a 5-l. bulb which was connected to a mass spectrometer inlet. It was found that the gas contained only SiF_4 and monomeric gaseous SiF_2 . Surprisingly, there was no evidence of a gas-phase reaction to give Si_2F_6 . (The other silicon dihalides all undergo gas-phase reactions producing Si_2X_6 . The carbon dihalides also react in the gas phase.) Within the flask, the concentration of SiF_2 fell to half its original value in about 150 sec. The SiF_2 decayed by reacting at the walls of the flask to form a polymer, and not by gas-phase reaction.

The half-life of gaseous SiF_2 was only slightly affected by adding BF_3 , CO, or PF_3 to the flask. Apparently there is no reaction between these compounds and SiF_2 in the gas phase. Oxygen did significantly reduce the half-life of SiF_2 ; the SiF_2 and O_2 reacted at the walls of the flask and silicon oxyfluorides were detected mass spectrometrically. This contrasts with the behavior of singlet CF_2 , which is not affected by O_2 .

For a summary of this early work see M. Schmeisser and P. Voss, Fortschr. Chem. Forsch., 9, 165 (1967); also see D. C. Pease, U. S. Patent 2,840,588 (June 24, 1958).
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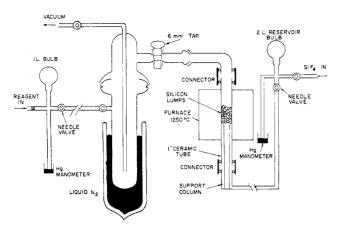


Figure 1. Apparatus for the preparation and reaction of SiF₂.

Some Properties of Polydifluorosilylene. When an SiF_2 - SiF_4 mixture is condensed into liquid N_2 , a redyellow deposit is formed. If this deposit is warmed to room temperature, it gradually turns white. The deposit is pliable, somewhat elastic, and quite tough; it can be cut with scissors. The overall stoichiometry of the deposit is $(SiF_2)_x$. With respect to its plastic properties and composition, $(SiF_2)_x$ is very much like its important relative, polytetrafluoroethylene, $(CF_2)_x$. Unfortunately $(SiF_2)_x$ is not inert; in fact, it is pyrophoric, burning spontaneously in air and reacting vigorously with water.

Two recent studies of $(SiF_2)_x$ have shown that its structure is very similar to that of $(CF_2)_x$. The Raman spectra of $(SiF_2)_x$ and $(CF_2)_x$ are comparable.⁵ The spectrum of $(SiF_2)_x$ confirms that the polymer does contain Si-Si bonds, as intuitively expected. The strength of these Si-Si bonds was established indirectly using fluorine bomb calorimetry.6 In this useful technique, some sample is placed in a container and this container is placed inside a second container filled with 4-5 atm of F_2 . A tungsten diaphragm separates the sample and the fluorine. This diaphragm is ignited electrically and the sample is exposed to the F2 in which it then burns vigorously. The temperature rise of the calorimeter is related to the energy released in the reaction. The Si-Si bond energy was determined to be 47 ± 7 kcal mol^{-1} . This compares with $51 \pm 10 \text{ kcal mol}^{-1} \text{ deter-}$ mined for some fluorosilanes by a mass spectrometric technique.7

One of the more useful properties of $(SiF_2)_x$ is that it can be used to prepare perfluorosilanes.⁴ When $(SiF_2)_x$ is heated to $\sim 200^\circ$ it begins to decompose. All of the perfluorosilanes, Si_nF_{2n+2} , from SiF_4 through $Si_{16}F_{34}$ have been detected as products; undoubtedly still higher silanes are also formed. These compounds can currently be prepared in no other way. Silanes containing above six silicon atoms are unusual and above ten silicon atoms very unusual. This preparation, yielding silanes with 16 silicon atoms, has therefore

great potential for the preparation of high molecular weight silanes.

Some Properties of Gaseous Silicon Difluoride. Before the reactions of SiF_2 can be discussed, something must be said of its physical parameters. These parameters have been measured in a number of experiments and are now well documented.

Possibly the most instructive study of gaseous SiF_2 has been the observation of its microwave spectrum.⁸ This was done simply by passing a SiF_4 – SiF_2 mixture through a conventional microwave absorption cell. In the singlet ground state, the Si–F bond distance was determined to be 1.591 Å and the F–Si–F bond angle to be 100° 59′. The dipole moment is 1.23 \pm 0.015 D.

The Si–F bond length is longer and the F–Si–F bond angle is smaller than might have been expected. For example, compare the bond angle $(100^{\circ} 59')$ with the bond angle $(119^{\circ} 30')$ for SO_2 , which is isoelectronic with SiF_2 . This has led to the suggestion that the bonding in SiF_2 involves mainly p^2 hybridization of the Si orbitals. The two nonbonding silicon electrons may have either pure s or sp character, although with silicon the possibility of d-orbital involvement must always be considered.

The infrared spectrum of gaseous SiF_2^9 was recorded between 1050 and 400 cm⁻¹. Two of the expected three absorption bands were observed. The other band was below the limits of the spectrometer. The two bands centered at 855 and 872 cm⁻¹ were assigned to the symmetric (ν_1) and antisymmetric (ν_3) stretching modes, respectively. The fundamental bending frequency (ν_2) 345 cm⁻¹ was already available from other studies.^{2,8,10} From these vibration frequencies and the bond lengths and angles determined in the microwave studies, the force constants of the molecule were calculated, as were its thermodynamic functions.

Ultraviolet emission spectra studies first proved the existence of nomoneric gaseous SiF2. The SiF2 was produced in small yield by passing an uncondensed electric discharge through SiF₄. Unfortunately in the first two studies band numberings were erroneous, so the early interpretations are incorrect.² An ultraviolet absorption study was undertaken in this laboratory,10 and 28 absorption bands were observed in the region between 2325 and 2130 Å. An interesting feature of this spectrum was the presence of a long progression in the bending frequency of the upper electronic state. This suggests that the F-Si-F angle undergoes a considerable change during transition. A series of bands with a periodicity of 252 cm⁻¹ was associated with the bending frequency of the excited state. The vibrationless transition lies at 2266.4 Å and is probably a ${}^{1}B_{1} \leftarrow {}^{1}A_{1}$ transition.

A further study of interest was a mass spectrometric

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⁽⁷⁾ J. D. McDonald, C. H. Williams, J. C. Thompson, and J. L. Margrave, Advan. Chem. Ser., No. 72, 681 (1968).

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⁽¹⁰⁾ V. M. Khanna, G. Besenbruch, and J. L. Margrave, *ibid.*, **46**, 2310 (1967).

determination of the heat of formation of $SiF_2(g)$.³ CaF_2 and Si were placed in a Knudsen cell and heated. The emission from the cell was monitored mass spectrometrically. The following data were obtained: $\Delta H_a^{\circ}_{298}(SiF_2,g) = 12.33 \pm 0.2 \text{ eV}$ and thence $\Delta H_f^{\circ}_{298}(SiF_2,g) = -139 \pm 2 \text{ kcal mol}^{-1}$. This value for $\Delta H_f^{\circ}_{298}$ is not very close to that estimated from transpiration studies, $-148 \pm 4 \text{ kcal mol}^{-1}$. It is thought that the formation of higher perfluorosilanes can explain the results of the transpiration study.¹²

Most of these properties are tabulated in Table I. Also listed are the corresponding values for CF₂ and GeF₂ which are also known.¹³ One of the more interesting comparisons is the M-F bond strengths. The Si-F average bond dissociation energy is higher than that of any other group IV elements for both the MF₂ and MF₄ species.¹⁴ This has important repercussions in the reaction chemistry of SiF₂.

Reactions of Silicon Difluoride

One of the first reactions of SiF2 to be studied was that with BF₃. 15 The reaction was carried out in what has now become the "usual" way. BF3 was continuously mixed with the SiF₂-SiF₄ mixture emerging from the furnace and then the whole mixture was condensed at -196° . When reactions are studied in this way, it is not completely clear whether most reactions occur upon condensation or while the mixed reagents are warming to room temperature. Studies of SiF₂ reactions in lowtemperature matrices are required to answer this question. With some reagents a highly colored polymer is formed, indicating there must have been some interaction between the reagents upon condensation. In other cases, however, there is no visible change and possibly reaction occurs upon warming. In either case, condensing the reagents presumably serves to cause reaction by increasing the local reagent concentration. As described earlier, there is no reaction in the gas phase; to get reaction the reagents must be condensed.

With SiF_2 – BF_3 a green condensate was formed. The condensate turned white upon warming and about 10% of the material condensed was evolved as volatile products. Excess SiF_4 and BF_3 were removed from the products by pumping on the condensate while cooling it to -90° . The products were then separated by passing them through a series of U tubes cooled to different temperatures. Two fractions were obtained, one at -50° and another at -25° . The relative amounts were 3:1.

When the first product was examined mass spectro-

Table I Some of the Properties of CF_2 , SiF_2 , and $GeF_2^{\ a}$

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Property	CF_2	SiF_2	GeF_2
Bond length, Å	1.300	1.591	1.7321
Bond angle	104° 56′	100° 59′	97° 10′
Dipole moment, D	0.46	1,23	2.68
$\Delta H_{\rm f}^{\circ}_{298,g}$, kcal mol ⁻¹	-39.3	-139	-136.9
\overline{D} , kcal mol ⁻¹	125	143	131
$T_{1/2}$, sec	1	150	Stable
Infrared fundamental			
frequencies ν_1 , ν_2 , ν_3 ,			
cm ⁻¹	1222, 668,	855, 345,	692, 263,
	1102	872	663

^a These properties were all measured in the gas phase.

metrically, the heaviest ion had m/e 181 (Si₂BF₆⁺). PVT methods indicated the molecular weight to be 201 \pm 2 and thus the molecular formula to be Si₂BF₇. The infrared spectrum showed bands in the Si–F and B–F region. The structure of the compound was conveniently determined using ¹⁹F and ¹¹B nuclear magnetic resonance. This proved that the compound was SiF₃-SiF₂BF₂. By similar methods the less volatile product was shown to be SiF₃SiF₂SiF₂BF₂.

Not very much is known about these two compounds. They thermally decompose at $\sim 500^{\circ}$. On reaction with iodine, they form BF₃, BI₃, SiI₄, SiF₄, and Si₂F₆. The presence of Si₂F₆ indicates that the iodine is attacking the Si-B bond rather than the Si-Si bond. With triethylamine, the liquid complex Si₂BF₇·N(C₂H₅)₃ is formed. When SiF₃SiF₂BF₂ and CO are mixed in the gas phase a number of products are formed, one of which has the molecular formula Si₂BF₅CO.

It is interesting to speculate about the SiF_2-BF_3 reaction mechanism. There are four considerations. (1) SiF_2 and BF_3 do not react in the gas phase. (2) The BF_3 must be present when the SiF_2 is condensed. When BF_3 is condensed onto a layer of SiF_2 , no reaction occurs. When SiF_2 is condensed onto BF_3 , reaction does occur. (3) The simplest member of the series SiF_3BF_2 is not formed. (4) When SiF_2 is condensed alone, $(SiF_2)_x$ is formed. Polymerization must proceed via a radical species $SiF_2(SiF_2)_xSiF_2$. These facts suggest the following reactions occur.

If reactions ii and iii are fast compared with iv and v, the low yields, the need for cocondensation, and the products formed are all simply explained.

When BCl₃ was allowed to react with SiF₂, no new products other than SiF_nCl_{4-n} were found. Apparently any silicon-boron product formed was too unstable to be purified.

The next reactions studied were those with benzene

⁽¹¹⁾ J. L. Margrave, A. S. Kana'an, and D. C. Pease, J. Phys. Chem., 66, 1200 (1962).

⁽¹²⁾ A. S. Kana'an and J. L. Margrave, Inorg. Chem., 5, 729 (1966).

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⁽¹⁴⁾ G. P. Adams, J. L. Margrave, R. P. Steiger, and P. W. Wilson, J. Chem. Thermodyn., in press.

⁽¹⁵⁾ P. L. Timms, T. C. Ehlert, J. L. Margrave, F. E. Brinckman,
T. C. Farrar, and T. D. Coyle, J. Amer. Chem. Soc., 87, 3819 (1965);
J. L. Margrave, P. L. Timms, and T. C. Ehlert, U. S. Patent 3,379,512 (April 23, 1968).

and some substituted benzenes.¹⁶ This series of reactions is particularly interesting since it is known that carbenes add to multiple bonds to form three-membered rings.

When SiF_2 and C_6H_6 were cocondensed at -196° , a brown polymer formed. On warming, this turned yellow and liberated unchanged benzene and perfluorotetrasilane. When the condensate was heated to 140°. a mixture of liquids and solids was produced. Mass spectrometric examination of this distillate showed that it contained a series of compounds of the type $C_6H_6(SiF_2)_n$, where n varied from 2 to at least 8. At low electron voltages only ions of the type C₆H₆+ and $C_6H_6(SiF_2)_n$ were seen. The most abundant compound was C₆H₆Si₃F₆. When this compound was hydrolyzed, the product was 1,4-cyclohexadiene. Infrared and ultraviolet studies showed that the compound does not have a conjugated double-bond system. These data, plus proton nmr studies, suggest that the compound has the structure

Although the compound with three SiF_2 units in the chain was produced in highest yield, all the compounds with from two to eight units were observed. When the reaction was repeated using toluene, the same products with methyl substitution were obtained. Fluorobenzene and p-difluorobenzene gave products equivalent to those obtained from toluene. These compounds are most unusual and cannot be synthesized by any other technique available at present. Little is known about their chemistry.

When hexafluorobenzene and SiF_2 react, products differing from those above are obtained. The major product has the molecular formula $C_6F_5SiF_3$ and was shown to be simply pentafluorophenyltrifluorosilane. Smaller amounts of the compound $C_6F_4(SiF_3)_2$ were also produced (ortho:para:meta $\sim 1:6:9$).

The reactions described above differ for fluorinated and for nonfluorinated aromatic systems. This difference was investigated further with respect to ethylene and fluorinated ethylene derivatives. With ethylene, two main products were obtained with molecular formulas $C_2H_4Si_2F_4$ and $C_4H_8Si_2F_4$. The nmr spectra of the compounds showed that they had the structures

$$H_2C$$
 SiF_2
 H_2C
 SiF_2
 H_2C
 SiF_2
 H_2C
 SiF_2
 H_2C
 SiF_2
 H_2C

When fluorinated ethylene derivatives were used, different products were formed. With tetrafluoro-ethylene only a white polymer was produced. When heated, this polymer exploded. This is simply explained: the Si-F bond is stronger than the C-F bond; upon heating the polymer rearranges to give carbon and SiF₄. Cautious heating of the polymer enabled compounds of the general formula $C_2F_4(SiF_2)_n$ (n=1,2,3) to be seen in a mass spectrometer. Possibly these species are three-, four-, and five-memberedring systems.

From the reaction of trifluoroethylene and SiF_2 several products were isolated. These were

These reactions show that there are differences between fluorinated and nonfluorinated systems. In the BF_3 – SiF_2 reaction, a mechanism based on the formation of diradical dimers, trimers, etc., was suggested. The same mechanism adequately explains the reaction of SiF_2 with benzene and ethylene. With hexafluorobenzene, however, it is difficult to imagine how the observed proportions of ortho, meta, and para derivatives could have been formed by diradicals. Also, the major products from both hexafluorobenzene and trifluoroethylene were monosilanes. In these cases monomeric silicon difluoride is the attacking species, probably forming the intermediate

By considering the bond energies, one finds that this system should rapidly rearrange to give

$$F$$
 C=C SiF_3 + energy

Several other multiple bond systems have been investigated. One of these is the butadiene–SiF₂ reaction.¹⁸ It is known that 1,3-butadiene reacts with tetrafluoroethylene to give, ultimately, the two compounds¹⁹

$$igcup_{\mathbf{F}_2}^{\mathbf{F}_2}$$
 $igcup_{\mathbf{F}}^{\mathbf{F}_2}$

With butadiene, SiF₂ reacts to give a compound of molecular formula C₄H₆Si₂F₄. Nmr examination showed the compound to have the structure

This product is analogous to that from C₂F₄ reaction, possibly indicating that a diradical mechanism operated in its formation.

(19) J. J. Drysdale, U. S. Patent 2,831,025 (Nov 1958).

⁽¹⁶⁾ P. L. Timms, D. D. Stump, R. A. Kent, and J. L. Margrave, J. Amer. Chem. Soc., 88, 940 (1966); J. L. Margrave and P. L. Timms, U. S. Patent 3,485,862 (Dec 23, 1969).

⁽¹⁷⁾ J. C. Thompson and J. L. Margrave, Chem. Commun., 566 (1966)

⁽¹⁸⁾ Work done in this laboratory, but as yet unreported, including studies by G. Besenbruch, F. Catrett, T. W. Harbaugh, J. Hastie, R. Hauge, G. Maass, K. G. Sharp, N. Szczepanski, J. C. Thompson, P. L. Timms, D. Williams, and P. W. Wilson.

SiF₂ also reacts with a number of acetylene derivatives. 18 With acetylene itself two products were formed. One of these was identified as

$$\begin{array}{c|c} H & C & SiF_2 \\ \parallel & \parallel & \\ C & SiF_2 \end{array}$$

The other product was a little more difficult to identify. The mass spectrum showed the molecular formula to be C₄H₄Si₂F₄; the molecular weight was confirmed by PVT methods. Hydrolysis of the compound yielded equal volumes of acetylene and ethylene. The compound therefore is

$$H_2C = CH - SiF_2 - SiF_2 - C = CH$$

A mechanism whereby this product might have been formed can be proposed by analogy with the ethylene reaction. An intermediate compound with the structure

may have formed. This would be unstable and should easily rearrange to give the observed product.

In reactions similar to that of acetylene, propyne and 2-butyne react with SiF₂ to give the compounds¹⁸

$$CH_3$$
 C SiF_2 CH_3 C SiF_2 CH_3 C SiF_2 CH_3 C SiF_2

Some Studies of the Silicon Difluoride Condensate.

In the reactions described above, it appears that in most cases the reactive silicon intermediate is the diradical $\cdot \operatorname{SiF}_2$ -SiF₂. This species was therefore sought in the SiF_2 - SiF_4 condensate.

The first method used to study this problem was infrared spectroscopy.²⁰ An SiF₂-SiF₄ mixture was diluted with argon (1:700) and the mixture was condensed onto a CsI window which had been cooled to 20°K using liquid hydrogen. This matrix was then allowed to warm gradually, and changes in the spectrum were noted. The resultant spectra are shown in Figure 2.

The first observation is that the peak at 811 cm⁻¹ disappears more rapidly than any other peak. Also, the peak is not observed at all if the furnace-to-window distance is long (10 ft or more). This suggests that the peak is due to some highly reactive species, possibly triplet SiF₂ or SiF and SiF₃ impurities. The next feature to observe is the appearance of the two bands at 892 and 830 cm⁻¹ as the matrix warms. As these bands grow, the band due to monomeric SiF₂ (855 cm⁻¹) decreases. These two new bands reach a maximum intensity at 38°K. At higher temperatures the new bands begin to disappear, and bands due to polymeric

(20) J. M. Bassler, P. L. Timms, and J. L. Margrave, Inorg. Chem., 5, 729 (1966).

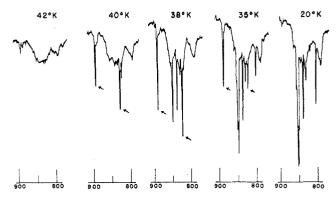


Figure 2. Infrared spectrum of SiF₂ in argon matrices.

silicon difluoride, (SiF₂)_x, appear. By 50°K polymerization appears to be complete. The behavior of the species in these spectra strongly indicates that monomeric SiF₂ is reacting to give polymeric diradicals and that these diradicals react to give the polymer.

Recently, there have been two reexaminations of the infrared spectrum of matrix-isolated SiF₂.²¹ These studies were oriented more to quantitative measures of physical parameters than to qualitative behavior. The ν_1 , ν_2 , and ν_3 fundamental frequencies were observed at 851, 343, and 865 cm⁻¹, respectively. Isotopic splitting was used to calculate a bond angle of 97–102°. These results agree with those obtained in the gas-phase stud-

A more definitive experiment, proving the presence of radicals in the condensate, was an electron spin resonance study.22 When the gaseous SiF2-SiF4 mixture was allowed to flow through the cavity of an esr spectrometer, no signal was observed. This confirms that the concentration of any triplet SiF₂ is very low, as the results of the microwave and electronic spectral studies suggested.

When the SiF₂-SiF₄ mixture was condensed on a cold finger in the cavity, a signal was produced. Radicals must be present in the condensate. The g factor for the resonance was determined to be $g = 2.003 \pm 0.002$, very close to the value that is usually found for a free electron.

As long as the condensate was kept cold, the signal intensity was constant. When the condensate was allowed to warm, the signal intensity began to drop. When the condensate reached room temperature, there was no residual signal.

The experiment also showed that the radicals are produced by interaction of SiF₂ molecules. A mixture of SiF₄, SiF₂, and Ar was condensed in the cavity; there was sufficient Ar to effectively isolate each SiF₂ molecule. This condensate gave no signal. If the amount of Ar dilutent was too low to ensure isolation, a signal was produced.

The infrared and esr studies show that there are

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(22) H. P. Hopkins, J. C. Thompson, and J. L. Margrave, J. Amer.

radicals in the condensate. These radicals are undoubtedly $(SiF_2)_n$ where $n=2,3\ldots$. Unfortunately neither experiment is quantitative, so it is impossible to tell if the radical concentration is high or low. In the SiF_2 -benzene reaction it appears that biradical chains must be the major reacting species. In the SiF_2 - C_6F_6 reaction the monomeric species seems to be the major reacting species. Apparently, then, both monomeric and polymeric SiF_2 species are present in the condensate. The specific reactants and reaction conditions determine which of the two species will be the major reactant.

Further Reactions of Silicon Difluoride

The first few reactions of SiF₂ studied were with organic molecules: benzene, toluene, alkenes, and alkynes. Since then a number of inorganic compounds have also been found to react, and these reactions have yielded new and interesting products.

Possibly one of the most interesting reactions of SiF₂ with an inorganic compound is its reaction with water.²³ When most silicon halides are hydrolyzed, polymeric oxides are formed. Intuitively, one might expect that the same would happen with SiF₂, especially in view of the fact that such polymers are produced in the reaction of SiF₂ with O₂.¹⁸ It has been reported that SiF₄ can be hydrolyzed to give volatile products if the conditions are strictly controlled. Under carefully controlled conditions it was hoped that nonpolymeric compounds might also be formed with SiF₂.

When H₂O and SiF₂-SiF₄ were cocondensed, a multicolored condensate formed; the color varied from yellow through green to white as the amount of H₂O was increased. When the condensate was warmed a number of products were formed. Several were easily identified as SiF₃H, SiF₃OSiF₃, and SiF₃OSiF₂OSiF₃. The latter two compounds were probably formed by the reaction of SiF₄ with H₂O.

Another product that formed was a new substance. By means of the usual physical methods of investigation, it was shown that this compound was 1,1,1',1'-tetrafluorodisiloxane, HF₂SiOSiF₂H. The most likely route for the formation of (SiF₂H)₂O is

$$\begin{split} \mathrm{SiF_2} + \mathrm{H_2O} &\longrightarrow \mathrm{HF_2SiOH} \\ \mathrm{2HF_2SiOH} &\longrightarrow \mathrm{HF_2SiOSiF_2H} + \mathrm{H_2O} \end{split}$$

Other reaction routes can be proposed, however, and may also play a part. The chemistry of (SiF₂H)₂O was studied in some detail to see if the Si-H or Si-O-Si bonds were more reactive than normal due to the presence of the fluorine atoms. The compound behaved in a similar fashion to other silanes and disiloxanes, so apparently the fluoride has little effect on the reactivity.

Another interesting reaction was that with CF₃I.²⁴ It was expected that the SiF₂ would simply insert into the CF₃-I bond to give CF₃(SiF₂)_nI-type products.

(CF₈I and CF₂CF₂ react to give CF₃CF₂CF₂I.) Actually three separate series of products were characterized

If CF_3I was in excess, CF_3SiF_2I was the major product; if SiF_2 was in excess, the number of higher silanes increased. It is interesting that, while each compound containing the CF_3 group also contained iodine, the reverse is not true. This observation led to the suggestion that SiF_2 initially abstracts an I atom from the CF_3I and that the resulting $\cdot SiF_2I$ reacts either with the residual $\cdot CF_3$ or with other neighboring groups.

To investigate further the reaction of SiF_2 with iodides, the reaction with I_2 itself was studied. The products were SiF_2I_2 and SiF_3I (yield 3:1). It is possible that the initial products were $SiF_2I \cdot SiF_2I$ and other di- or trisilanes. I_2 might cleave the Si-Si bonds to give monosilanes. On the other hand, the SiF_2ISiF_2I produced in the CF_3I-SiF_2 reaction was stable to I_2 , as are Si_2H_5I and $Si_2H_4I_2$. It is probable then that monosilanes were the initial products, and so the reacting species must have been monomeric SiF_2 .

 SiF_2 and H_2S react to give mainly SiF_2HSH and Si_2-F_5H . The analog to the product obtained in the H_2O-SiF_2 reaction, SiF_2HSSiF_2H , was not observed. The disilanethiol, SiF_2HSiF_2SH , expected from insertion of SiF_2SiF_2 into the H-SH bond was recovered in only small amounts, although this might have been due to its instability.

Several reactions of SiF_2 with silanes and germanes have been reported. SiF_2 and GeH_4 react to give products of the type $GeH_3(SiF_2)_nH$, $n=1-3.^{27}$ The stability of these compounds decreases rapidly as n increases. To date, the reaction of SiF_2 with SiH_4 has not been reported. SiF_2 does not appear to react with $Si(CH_3)_4$, $Si(CH_3)_3Cl$, or $Ge(CH_3)_4$. 28 SiF_2 reacted with $Si(CH_3)_3OCH_3$ to give $Si(CH_3)_3F$, $Si(CH_3)_3Si(CH_3)_2F$, CH_3OSiF_3 , and $Si(CH_3)_3SiF_3$. The formation of these products suggests that the SiF_2 initially inserted into the Si-O bond but that the product was unstable and decomposed.

The reaction of SiF₂ with $(CH_3)_2SO$ gives $(CH_3)_2SF_2$ and $(SiF_3)_2O$.¹⁸ In some way, the oxygen has been abstracted from the sulfur. Much the same happened in the reaction with SOF_2 . The only silicon-containing products were cyclic fluorosiloxanes.^{18,29} The mechanisms of these reactions are not understood.

A class of reactants which gives products that are very hard to characterize is carbonyl compounds, especially ketones and acid halides. In most cases liquids of very low vapor pressure have been formed with re-

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actants such as $(CF_3)_2CO$, CF_3COF , and CF_3COCl . These liquids have not yet been successfully characterized. It is interesting that CF_2 does not react with the carbonyl group.¹³

The reactions of SiF₂ with nitrogen-containing compounds have not as yet yielded new compounds.¹⁸ Deeply colored polymers are formed, indicating that some reaction has occurred upon cocondensation. When the condensate is warmed, however, no compounds containing both Si and N are found. Reagents used have been N₂O, NO, NO₂, NOCl, NOF, and NH₃.

When BF₃ is passed over B at 2000°, BF is produced. This BF-BF₃ mixture has been condensed with a SiF_2 - SiF_4 mixture. Two new compounds, $F_2Si(BF_2)_2$ and $FSi(BF_2)_3$, were recovered from this condensate.³⁰

Another reaction yielding new products was that with methanol.³¹ The products recovered indicated however that the CH₃OH first reacted with the SiF₄ in the gas phase, forming CH₃OSiF₃ and HF. The HF and the SiF₂ reacted upon condensation to give SiF₃H. There was some reaction of SiF₂ with methanol, probably to form CH₃OSiF₂H, which then reacted with excess CH₃OH to form the recovered product, (CH₃O)₂SiF₂.

The reactions of SiF₂ with NaF and LiF have been studied.¹⁸ The alkali fluorides were evaporated from a Knudsen cell and cocondensed with SiF₂. Although it appears that new products are formed at low temperatures, they are not thermally stable. Probably the low-temperature species (M+,SiF₃-) are formed. When warmed to about 0° they decompose to give M₂SiF₆ and Si. Reaction between SiF₂ and Na to yield (Na+,SiF₂-) has also been observed in matrix studies.¹⁸

There have also been attempts to observe reaction of SiF₂ with the compounds GeF₄, CF₄, ·CF₃, CF₂, CF₂=CF₂, C₂F₆, and perfluorocyclobutane. The course of these reactions is easily predicted since the Si-F bond is considerably stronger than other M-F bonds for group IV elements. There is normally a rapid (sometimes explosive) exchange giving SiF₄ and C or Ge. Reactions with this type of compound should be approached cautiously.

Finally, it is necessary to point out that sometimes products cannot be recovered from the condensate. When SiF₂ reacts with nitriles (CF₃CN, CH₃CN, CNCl, (CN)₂), a black condensate forms. The only products that have been recovered from this condensate, even after strong heating, are perfluorosilanes and triazine derivatives.¹⁸

Thus far in the development of the chemistry of SiF_2 it has only been possible to predict the course of a specific reaction in broad terms. In some cases the reactive species seem to be polymeric diradicals, notably

Si₂F₄, and in other monomeric SiF₂. From consideration of all of the reactions studied, two hypotheses emerge. First, diradicals only take part in reaction when a bond of sufficient reactivity to be attacked by monomeric SiF₂ is not present. The extreme negative extension of this case is seen in the reaction of SiF2 with CCl₃H; ¹⁸ unreacted CCl₃H and polymeric (SiF₂)_x are recovered from the condensate. This idea can be expressed in another way. There are two competing reactions: (a) the reaction of SiF₂ with the reagent, and (b) the polymerization of SiF₂. The rate of reaction seems to be far more important than the thermodynamic stability of the products. In turn, the reaction rate depends on activation energy. The activation energy for polymerization is low (say 1 or 2 kcal mol⁻¹), and if monomeric SiF₂ is to react with the other species, the activation energy for this reaction must be even lower. Second, with attention especially to the CF₃I and H₂S reactions, it appears that monomeric SiF₂ may react in a stepwise fashion, abstracting a single atom or group from the reactant and then reacting with any nearby species.

Conclusions

The studies described above have shown that SiF_2 is a versatile reagent which reacts with both organic and inorganic compounds. The products obtained are often unique and almost invariably interesting. New classes of compounds have been prepared with many reagents, and with others new members have been added to existing classes. Development of the chemistry of SiF_2 will doubtless provide many more new organic, inorganic, and organometallic compounds.

Rather than suggest new reagents to try, however, it seems important here to point out that there are some fields of SiF₂ chemistry which have received little attention to date. First, all of the work so far was with singlet SiF₂. Techniques leading to the production of triplet or excited SiF₂ should be investigated. Triplet CF₂ has a broadly developed gas-phase chemistry and that of triplet SiF₂ should also be interesting. Second, it has been noted by Pease^{1,32} that if gaseous SiF₂ and any halogen were passed through a furnace at 1200°, gas-phase reaction occurred. Some of the gasphase chemistry of monomeric singlet SiF₂ could be investigated in this way. Finally, all the reactions reported to date have been initiated by cocondensation at -196° . It appears that the reaction rate is the most important factor in controlling the ultimate course of SiF₂ reactions. The rates of reactions with low activation energies (3-5 kcal mol⁻¹) are strongly affected by small temperature differences. Cocondensation at temperatures higher than -196° may lead to reactions that do not occur at lower temperatures and may also alter the course of those reactions that are known to occur.

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Symmetry Rules for Chemical Reactions

RALPH G. PEARSON*

Department of Chemistry, Northwestern University, Evanston, Illinois 60201 Received September 10, 1970

Recently there has been great interest in the devising of symmetry rules for predicting the course of chemical reactions. Much of this interest is due to the wellknown work of Woodward and Hoffmann. Their method is based upon a correlation of the molecular orbitals of the reactant(s) with those of the product(s), and can be considered quite general. In this Account we present symmetry rules, derived in quite a different manner, whose predictions are not expected to differ from the most generalized application of the Woodward-Hoffmann rules but which are usually easier to apply.

Molecular orbital theory is still used as a basis, but the chemical reaction is considered as a perturbation on the reactant system. In particular, a small displacement along the reaction coordinate is taken as the perturbing influence. Using the quantum mechanical method of second-order perturbation theory, the symmetry rules for an elementary process of any molecularity can be stated in a rigorous way. This was first done by Bader¹ for the decomposition of an activated complex, a special example of a unimolecular reaction. The corresponding rules for bimolecular reactions have only recently been stated.² However the same conclusions can be drawn from a number of other perturbation theories of chemical reactivity.3

The mathematical language of group theory is useful in stating the symmetry rules in a concise way. Fortunately the conclusions can also be stated in a simple, pictorial manner. It is necessary to have some knowledge of the molecular orbitals of the system. In particular, the symmetry properties are needed. These are simply the changes in sign (plus or minus) of the

wave function, corresponding to the MO, at different parts of the molecule.

Chemical reactions consist of the breaking of certain bonds between atoms and the making of new bonds. All MO's correspond to the bonding together of certain atoms, the antibonding of other atoms, and the nonbonding of the remaining atoms. It follows that in a chemical reaction certain molecular orbitals must be vacated of electrons and others must be filled to create the new bonding situation.

The most important of these changes is a flow of electrons from the highest occupied molecular orbital (HOMO) to the lowest unoccupied molecular orbital (LUMO). The importance of these orbitals has been stressed by Fukui, who in 1952 named them the frontier orbitals.

Electron movement between two orbitals cannot occur unless the orbitals meet the symmetry requirement. For a bimolecular reaction, the requirement is simply that the two have a net overlap. For a unimolecular reaction, the symmetries of the two must match up with the symmetry of the motion of the nuclei. The nuclear motion can be regarded as equivalent to one or more of the normal modes of vibration of the molecule.

Theory

Consider an elementary process (concerted reaction) of any molecularity. The question is, how does symmetry enter into the variation of potential energy with changing nuclear coordinates? Group theory will first be used to obtain an exact answer to this question. The applications made later do not require the use of group theoretic language, but it is obvious that there are many reasons for chemists today to become familiar with the symbols used.

Figure 1 shows the usual adiabatic plot of potential energy vs. reaction coordinate. The points marked A, B, and C will be used to derive the symmetry rules since they represent characteristic features of such a plot. Any point on the diagram corresponds to some arrangement of the nuclei of the reactants. This ar-

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